

MATERIALS SCIENCE

Ferroelectricity in a semiconducting all-inorganic halide perovskite

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Ferroelectric semiconductors are rare materials with both spontaneous polarizations and visible light absorptions that are promising for designing functional photoferroelectrics, such as optical switches and ferroelectric photovoltaics. The emerging halide perovskites with remarkable semiconducting properties also have the potential of being ferroelectric, yet the evidence of robust ferroelectricity in the typical three-dimensional hybrid halide perovskites has been elusive. Here, we report on the investigation of ferroelectricity in all-inorganic halide perovskites, CsGeX₃, with bandgaps of 1.6 to 3.3 eV. Their ferroelectricity originates from the lone pair stereochemical activity in Ge (II) that promotes the ion displacement. This gives rise to their spontaneous polarizations of ~10 to 20 $\mu\text{C}/\text{cm}^2$, evidenced by both *ab initio* calculations and key experiments including atomic-level ionic displacement vector mapping and ferroelectric hysteresis loop measurement. Furthermore, characteristic ferroelectric domain patterns on the well-defined CsGeBr₃ nanoplates are imaged with both piezo-response force microscopy and nonlinear optical microscopic method.

INTRODUCTION

Ferroelectrics are characterized by a switchable spontaneous polarization that results from long-range ordered electric dipoles (1). The switching of polarization under applied electrical field, as well as the control of polarization responses with temperature or strains, makes ferroelectric materials desirable for various technologies, including switching devices, sensors, and nonvolatile memories (2, 3). Coupling ferroelectricity with photoexcitation in semiconductors could further enhance the material functionality, whereby light can take the role of an additional control knob for inducing previously unknown physical phenomena and tuning properties beyond the conventional ferroelectric behaviors (4–7). Particular examples include the optically controlled polarizations (8) for optical switches and polarization-induced charge separation being called ferroelectric photovoltaic effect (4–6, 9, 10). However, the design of effective optical switches or ferroelectric photovoltaics under solar illumination critically depends on materials with both substantial polarizations and efficient visible light absorptions, that is, ferroelectric semiconductors.

Since the prototypical ferroelectrics such as perovskite oxides (ABO₃) generally have wide bandgaps (3 to 5 eV) with very few exceptions, i.e., BiFeO₃ (2.7 eV), the search and design of ferroelectrics with suitable bandgaps in the visible regions have attracted much attention. Among these efforts, elemental doping in the oxide perovskites has proven effective in achieving reduced bandgaps, exemplified by Ni-doped KNbO₃ and PbTiO₃ (10, 11). The identification of

ferroelectricity in other semiconducting nonperovskite systems such as SbSI (12) and GeTe (13) has also been reported, although an unstable ferroelectricity in these materials has sparked debates (1). Low carrier mobilities or weak light absorptions also limit the application of all these material platforms.

Halide perovskites (ABX₃, X are halides) are structurally analogous to the oxide perovskites but are readily a new class of semiconductors by themselves (bandgaps of 1 to 3 eV), different from their wide-bandgap insulating oxide counterparts. Much research has focused on the unprecedented performance of halide perovskites as photoactive materials for optoelectronics due to their strong light absorption, tunable photoresponse, efficient carrier transport properties, and ease of processing (14–17). It is thus intriguing to explore the potential ferroelectricity in halide perovskites, where the coupling among these behaviors may result in the emergence of new ferroelectric semiconductors. Although ferroelectric responses have been reported in some organic-inorganic halide perovskites (18, 19), the nature of the polar order in some of the hybrid materials (e.g., CH₃NH₃PbI₃) still remains unclear, as the dynamic organic species with chemical and mechanical inhomogeneities can obscure the origin of the polarity and ferroelectric domain-like features (20, 21). On the other hand, it is highly desirable to exclude the volatile organic components that are thermally unstable and develop all-inorganic candidates for practical device fabrications.

CsGeX₃ (X = Cl, Br, I) is the only class of inorganic halide perovskites with a noncentrosymmetric crystal structure (22–24) that could lead to potential ferroelectric properties. Here, we present the experimental discovery of ferroelectricity in semiconducting CsGeX₃. We attained the synthetic control for producing single-crystalline CsGeBr₃ (CGB) nanowires and nanoplates by facile chemical vapor transport (CVT) methods. The CGB nanostructures have a bandgap of 2.38 eV, exhibiting strong visible light absorption and photoreponses. Atomic displacement vector mapping and macroscopic polarization hysteresis loop measurement (on both CGB nanowire and CsGeI₃ thin film) established the existence of ferroelectricity, with the spontaneous polarization of ~10 to 20 $\mu\text{C}/\text{cm}^2$ that matches

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with ab initio calculations. Moreover, the well-defined CGB nanoplates are especially suitable for imaging the self-organized polar domains using piezo-response force microscopy (PFM) and polarization-resolved second-harmonic generation (SHG) microscopy. We anticipate that this study will open a pathway for further exploration into this class of semiconducting ferroelectric materials and trigger new possibilities in developing previously underexplored multifunctional materials such as photoferroelectrics.

RESULTS AND DISCUSSION

Symmetry analysis and structural characterizations

CsGeX₃ crystallizes in a perovskite structure at room temperature (RT) with a rhombohedral distortion from the pseudo-cubic framework, as illustrated in Fig. 1A (X as Br here). The distortion of the octahedra originates from the Ge displacement from the center of the octahedron, along the direction parallel to the body diagonal of the pseudo-cubic cell ($\langle 111 \rangle_{pc}$), which contributes to the electric

dipole formation in each unit cell. CGB exhibits a low-symmetry rhombohedral phase below 238°C (511 K) (25) and that transforms into a high-symmetry cubic phase at higher temperature (Fig. 1A). The displacement of the Ge ion in the low-symmetry phase along the body diagonal of the pseudo-cubic structure yields three longer Ge—Br bonds (3.051 Å) and three shorter ones (2.541 Å); this structure can also be viewed as an arrangement of tetrahedrally coordinated [GeBr₃][−] units. The stereochemically active lone pair (4s²) of Ge (II) cation can play a central role in promoting the Ge off-centering displacement (26) and stabilizing structural distortion that generates the spontaneous polarization.

Through an atmospheric pressure CVT growth process developed in-house (Materials and Methods), CGB nanoplates and nanowires were successfully obtained, which were subsequently used as the model systems for structural characterizations and studies of the material properties. The CGB growth via CVT does not require sophisticated conditions and is also compatible with various substrates including silicon, mica, quartz, and oxide perovskites. Figure 1B

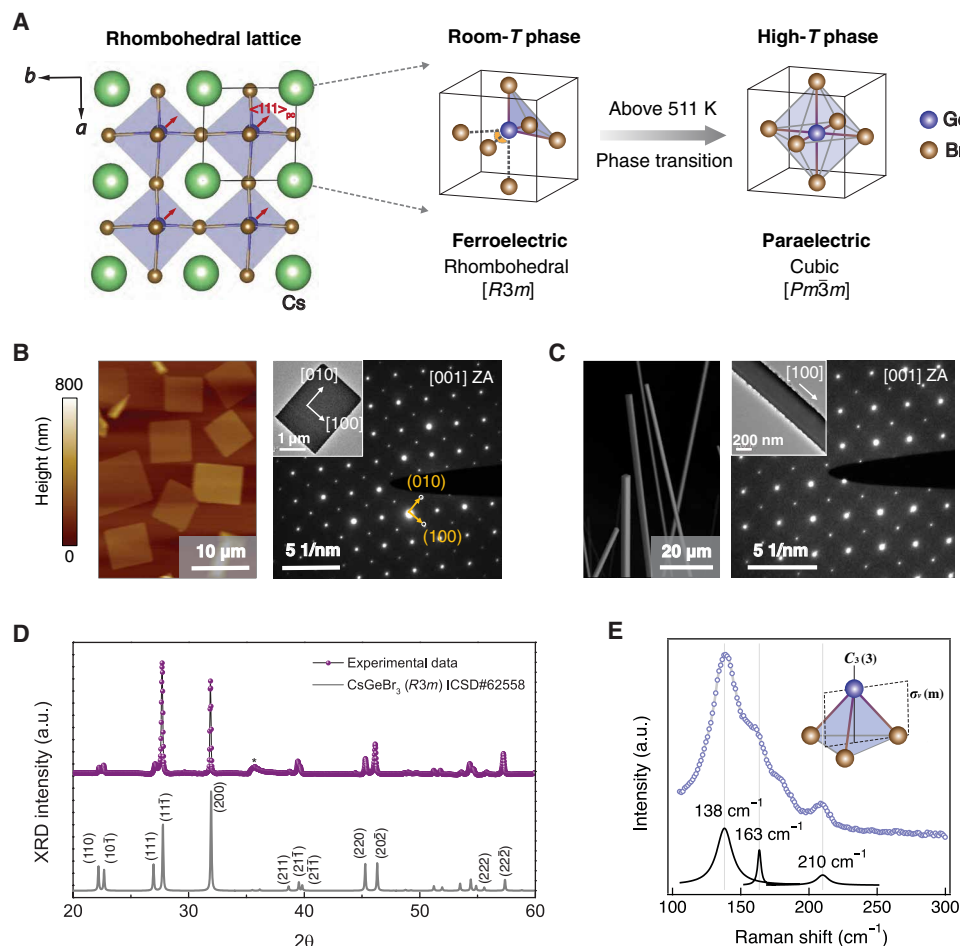


Fig. 1. Structure characterizations of CsGeBr₃ nanostructured single crystals. (A) The left panel shows a projected lattice view of CsGeBr₃ (CGB) perovskite structure, which features the Ge displacement along the $\langle 111 \rangle_{pc}$ direction in each unit cell. The subscript “pc” denotes pseudo-cubic. The right panel shows a 3D view of the unit cells to illustrate the Ge coordination environments of CGB in two different phases upon ferroelectric phase transition, where Cs atoms at all corners are not sketched for simplicity. (B) Typical topography (AFM) of the CGB nanoplates and the associated SAED pattern from one nanoplate shown in the TEM image (inset), with relevant crystallographic axes and planes labeled. “ZA” denotes the zone axis. (C) SEM image of the CGB nanowires and the associated SAED pattern from nanowire shown in the inset TEM image. (D) Synchrotron x-ray microdiffraction of an individual CVT-grown CGB crystal at RT ($\lambda = 1.54982$ Å). Standard pattern shown in the bottom was indexed using the Inorganic Crystal Structure Database. a.u., arbitrary units. (E) Raman spectroscopy of CGB nanoplates at RT (633-nm excitation). The phonon modes are related to the [GeX₃][−] tetrahedron with C_{3v}(3m) symmetry (inset).

represents the topographic feature of an assembly of uniformly distributed square CGB nanoplates taken from atomic force microscopic (AFM) imaging, with lateral width of micrometer scale and thickness on the order of hundred nanometers. We transferred a very thin nanoplate from the growth substrate to the copper grid for transmission electron microscopy (TEM) studies. Energy-dispersive x-ray spectroscopic (EDS) measurement and mapping from TEM confirmed the correct atomic ratio as Cs:Ge:Br \approx 1:1:3 for the CGB nanoplate (fig. S2). A selected-area electron diffraction (SAED) pattern is also shown in Fig. 1B, together with the corresponding TEM image (inset), indicating the single-crystalline nature of the CGB nanoplate and also revealed a pseudo-cubic crystal symmetry. Indexing of this SAED pattern with pseudo-cubic indices in the (001) projection yields the average lattice spacing of 5.635 Å for {100} planes and a distortion angle of 1.3° from the cubic symmetry, in agreement with the standard crystallographic data (27). We thus identified that the edges of nanoplate are oriented in the <100> direction, while the top surface is the (001) facet. Such symmetry correlations between the crystal structure and the sample geometry can be attributed to the high pseudo-cubic symmetry of the germanium halide perovskites. We also present a typical morphology and crystallographic information of the CVT-grown CGB nanowires with scanning electron microscopic (SEM) image and SAED pattern with the corresponding TEM image (Fig. 1C). Elemental distribution and ratio were also confirmed by EDS mapping on individual nanowires (fig. S3). Controlled growth helped producing CGB nanowires in either horizontal distribution or vertical alignment to the substrates for different characterizations and measurements (fig. S4).

Structural analysis for the overall CVT-grown CGB crystal assembly using both synchrotron x-ray microdiffraction (Fig. 1D) and laboratory powder x-ray diffraction (XRD) (fig. S5) further demonstrated the rhombohedral phase and confirmed the pseudo-cubic lattice parameter of 5.635 Å. Besides the macroscopic structural analysis through XRD, Raman spectroscopy serves as a great tool for observing the vibrational properties of the local symmetry. As shown in Fig. 1E, the Raman spectrum of the CGB nanoplates confirmed this characteristic with the three most representative peaks, 138, 163, and 210 cm⁻¹, corresponding to the *E*, *A*₁ (transverse), and *A*₁ (longitudinal) modes, respectively, of the 3*m* (*C*_{3*v*}) symmetry. Additional Raman peaks in low-frequency (<100 cm⁻¹) range are shown in fig. S6, all consistent with earlier studies for bulk crystals (28). The inversion symmetry breaking in these CGB nanoplates is corroborated by the presence of SHG. The optical SHG effect is characterized as exactly doubling the fundamental light frequencies, with the SHG intensity quadratically depending on the input power of fundamental light (fig. S7). Temperature-dependent SHG

(fig. S8) exhibits an abrupt change in the SHG intensity of CGB at around 238°C (*T*_C, Curie temperature), which further verifies the phase transition from a noncentrosymmetric phase at low temperature to a centrosymmetric phase at high temperature.

Semiconductor behaviors

As an illustration of the semiconducting property in this class of perovskite, we first determined the bandgap of the CGB nanoplates from ultraviolet-visible (UV-vis) absorption spectroscopy as around 2.38 eV (fig. S9A), which is narrower than ferroelectric perovskite oxides. The sharp absorption edge also indicates that it is a direct bandgap semiconductor as for the lead halide perovskites. In addition, UV-vis absorption spectroscopy results from all CsGeX₃ (X = Cl, Br, I) crystals verified their light absorption behavior within the visible spectrum range, with bandgaps of 1.6 to 3.3 eV (fig. S9B). We also measured the current-voltage (*I*-*V*) characteristics of the CGB nanowires under dark and light conditions (fig. S10). The conductance under light illumination can increase to 5 to 10 times of that under dark condition, again a characteristic photoresponse for typical semiconductors. As a ferroelectric semiconductor, the resistivity (under dark) of the germanium halide perovskite is around 10⁶ to 10⁸ ohm · cm, several orders of magnitude lower than that of the conventional ferroelectric perovskite oxides.

Analysis of ferroelectric polarization

To understand the origin of ferroelectricity in CGB, we performed ab initio calculations to investigate the high- and low-symmetry structures and the resulting spontaneous polarizations. The details of the calculations and the full set of results for the CsGeX₃ series (X = Cl, Br, I) are given in Materials and Methods and Table 1, respectively. Our discussion here is focused on the case of CGB. First, we performed full structural optimizations of both the high-symmetry cubic *Pm* $\bar{3}$ *m* phase and the low-symmetry polar rhombohedral *R3m* phase, finding that the latter phase is 85 meV per formula unit lower in energy as expected. Next, we calculated the spontaneous polarization (*P*_s) using the Berry phase approach by interpolating between the undistorted (cubic) structure and the polar (rhombohedral) structure to identify the correct branch cuts for polarization values (29, 30). Our results are summarized in Fig. 2A with the total polarization calculated being a sum of the ionic and electronic contributions, giving a final value 19.7 μC/cm² in the RT distorted phase along the <111> direction. The spontaneous polarization of CGB can also be estimated from multiplying the Born effective charges (BECs) of the displaced ions by their displacements in the polar structure (Table 1). For CGB, we calculate the BEC of Ge to be 5.37*e*, and with a Ge displacement of 0.27 Å, resulting in a *P*_s of 12.2 μC/cm². This is smaller than the

Table 1. DFT calculated spontaneous polarization for CsGeX ₃ (X = Cl, Br, I) for the rhombohedral (<i>R3m</i>) phase using both a BEC estimation and a full Berry phase calculation, in comparison with the experimental result for CsGeBr ₃ single crystal and CsGeI ₃ thin film reported here.					
	BEC (<i>e</i>)	Ge displacement along <111> (Å)	<i>P</i> _s (μC/cm ²) BEC estimated	<i>P</i> _s (μC/cm ²) Berry phase calculated	<i>P</i> _s (μC/cm ²) Experiment
CsGeCl ₃	4.799	0.237	10.7	18.5	\
CsGeBr ₃	5.372	0.271	12.2	19.7	12–15
CsGeI ₃	6.175	0.318	13.7	18.6	~20

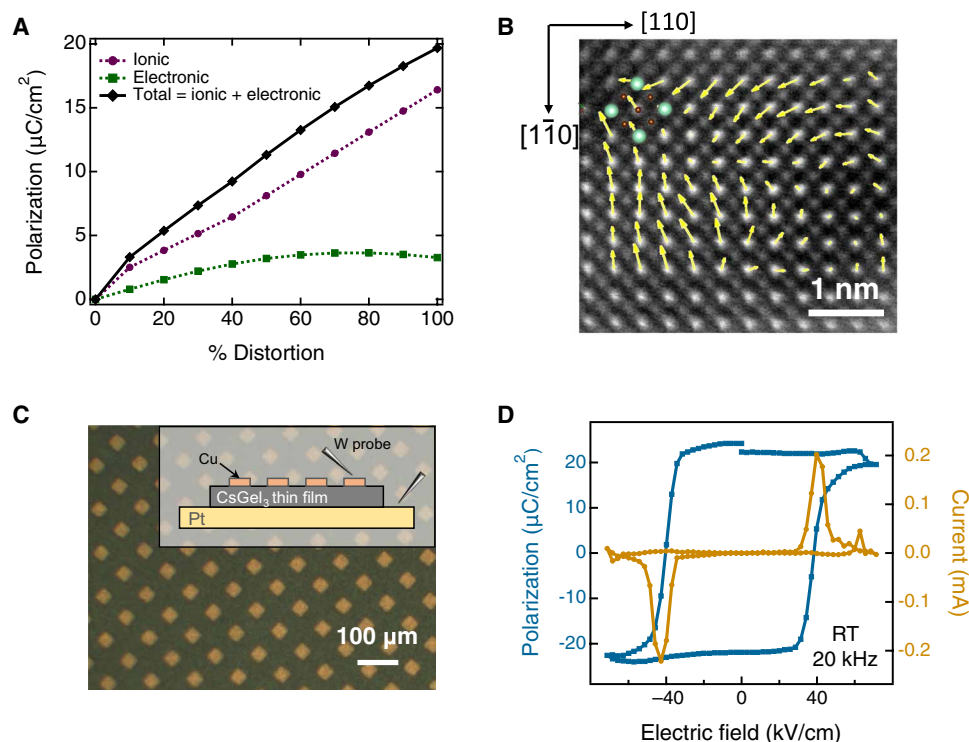


Fig. 2. Theoretical and experimental evidence of the ferroelectric polarizations. (A) Berry phase calculations of the polarization versus distortion percentages for CGB, in which 0% distortion means the cubic phase and 100% distortion means the ferroelectric rhombohedral phase. (B) Atomic-resolution STEM image on a localized domain of CGB nanowire displays the atomic displacement vector map. (C) Optical microscopic imaging of the patterned Cu electrodes (area of each electrode, 30 μm by 30 μm) on the CsGeX₃ thin film (thickness, 350 nm). Inset: Sketched side view of the device structure (Cu–perovskite film–Pt) for the hysteresis measurement. The voltage is applied to the perovskite film through the two tungsten (W) probes. (D) Current versus electric field loop after subtracting the leakage contribution and the corresponding ferroelectric hysteresis loop, obtained from the measurement on the device shown in (C).

value obtained from the Berry phase approach, indicating a substantial electronic charge redistribution. The anomalously high values of the BEC compared to its formal ionic values of $2e$ in the Ge²⁺ indicate significant charge transfer between cations and anions in this structure, and is a strong indicator of ferroelectric polarization. Last, we investigate the origins of ferroelectricity in CGB, which could be potentially driven by the stereochemically active $4s^2$ lone pair on Ge (II) (26). In fig. S11, we plot the real-space charge density for the polar $R3m$ structure, indicating an acentric electronic distribution along the $\langle 111 \rangle$ direction, corresponding to the Ge off-centering. We also calculated the orbital-projected density of states (fig. S12), which shows that the top of the valence band is composed mainly of Ge- s and Br- p states, as expected for $4s^2$ lone pair-driven ferroelectricity.

The key experimental signatures of the ferroelectric polarization in CGB were obtained and are detailed in this and following sections. First, the atomic-resolution scanning TEM (STEM) imaging can be used for characterizing the polarizations and structural distortions from the atomic level. Figure 2B exhibits a high-angle annular dark field (HAADF) of STEM image taken from a domain (with zone axis of $[001]_{\text{pc}}$) on the CGB nanowire, where the atomic-scale polarization mapping was performed using a displacement vector-mapping algorithm (Materials and Methods). This displacement vector map displays atomically resolved lattice distortion and polarization distribution, with the average magnitude of the displacement vector for each atom of ~ 6 pm, consistent with the

calculated spontaneous polarization values discussed above. As the CGB nanowires are extremely beam sensitive at RT for STEM imaging (fig. S13), we obtained the useful STEM images on sample at liquid nitrogen temperature. It should be noted that there is no phase transition in CGB at such low temperature (25).

To examine the macroscopic polarization and electrical switchability of CsGeX₃, we performed the ferroelectric hysteresis measurements. We first fabricated a CGB nanowire device and measured the hysteresis loops as shown in figs. S14 and S15. From the polarization-electrical field (P - E) hysteresis loop, one can identify an experimental value of P_s in CGB to be around 12 to 15 $\mu\text{C}/\text{cm}^2$. However, we note that the hysteresis loop does not saturate, i.e., these are minor loops, likely because of the limitations in the maximum applied electric field due to this undesirable device design (see discussions in the Supplementary Materials). It could also be due to the effects of leakage current and dielectric contribution convoluting the observed hysteresis loop. Especially, the low resistivity of CsGeX₃ may contribute to a strong leakage current contribution to the unsaturated hysteresis loops. To mitigate such effects, we performed pulsed measurements of ferroelectric polarization, known as the positive-up-negative-down (PUND) test (31, 32). The PUND result (fig. S16) also reveals above-zero switched polarizations (or charges). Furthermore, we developed a more preferable test protocol based on device with a thin-film geometry as shown in Fig. 2C (see Materials and Methods). To reveal the typical P - E loop resulting only from the polarization switching contribution, we measured the current-electric

field loop and obtained a reconstructed P - E loop (Fig. 2D) after subtracting the leakage current contribution (see figs. S17 and S18). From this saturated hysteresis loop, we can have more accurate interpretations on the coercive field and remanent polarization of the CsGeI₃ film, which are around 40 kV/cm and 20 $\mu\text{C}/\text{cm}^2$, respectively.

PFM and local switching spectroscopy

We further probed the piezoelectric response and ferroelectric domain formation of the CGB nanoplates using PFM. The ferroelectric phase CGB features a spontaneous polarization oriented along one of the eight $\langle 111 \rangle$ directions in the pseudo-cubic cell (fig. S19). Since the two-dimensional (2D) geometry of CGB nanoplate is a projection of the 3D nature in crystal lattice, we used vector PFM to completely reveal the polarization orientations and associated domain configuration. With direct correspondence to the crystal symmetry, the CGB nanoplates serve as an ideal platform for investigating how the polarization directions are distributed among different domains. Figure 3 (A and B) presents the PFM phase images of one CGB nanoplate under two orthogonal in-plane modes, while the corresponding out-of-plane phase and AFM topographic images are shown in fig. S20. From the in-plane PFM phase images, the in-plane projection of polarization in this individual nanoplate can be interpreted, which contains four vectors pointing outward toward the nanoplate corner, all in parallel to the face diagonal direction. The out-of-plane polarization component is upward (fig. S20A). As

a result, the different polarization orientations in the four domain variants can be represented with the four vectors (P_1 , P_2 , P_3 , P_4) shown in Fig. 3C. Each of them corresponds to one of the $\langle 111 \rangle$ directions in pseudo-cubic cell. Therefore, it is clear that the CGB nanoplate with thickness of 130 nm (fig. S20, C and D) favors to form this divergent domain configuration. These microscopic domains (typically with several micrometers in width) form due to the net uniformly oriented polarization vector in each of them. A schematic overview of the domain configuration with geometric correspondence to the nanoplate was presented in fig. S20B. Another separate example of domain imaging by in-plane phase contrast is presented and accompanied by the corresponding topographic imaging (Fig. 3, D and E). Notably, the CGB nanoplates all display stronger phase contrasts in the in-plane PFM images than in the out-of-plane ones, indicating that the in-plane polarization orientation varies but the out-of-plane is common on a single CGB nanoplate. Various domain patterns may appear on different nanoplates with different thicknesses, as shown in figs. S21 and S22. We also observed a striped, twin-like domain pattern (along $\langle 110 \rangle_{\text{pc}}$ direction) on the nanoplate shown in Fig. 3 (D and E), with the magnified in-plane amplitude images in Fig. 3F and corresponded line profile in Fig. 3G. The spacing of the stripes is measured to be around 80 to 100 nm, suggesting the domain width of the nanometer scale, apparently distinctive from that of the microscopic domains. The formation of these twin-like domains (also in fig. S23) can be attributed

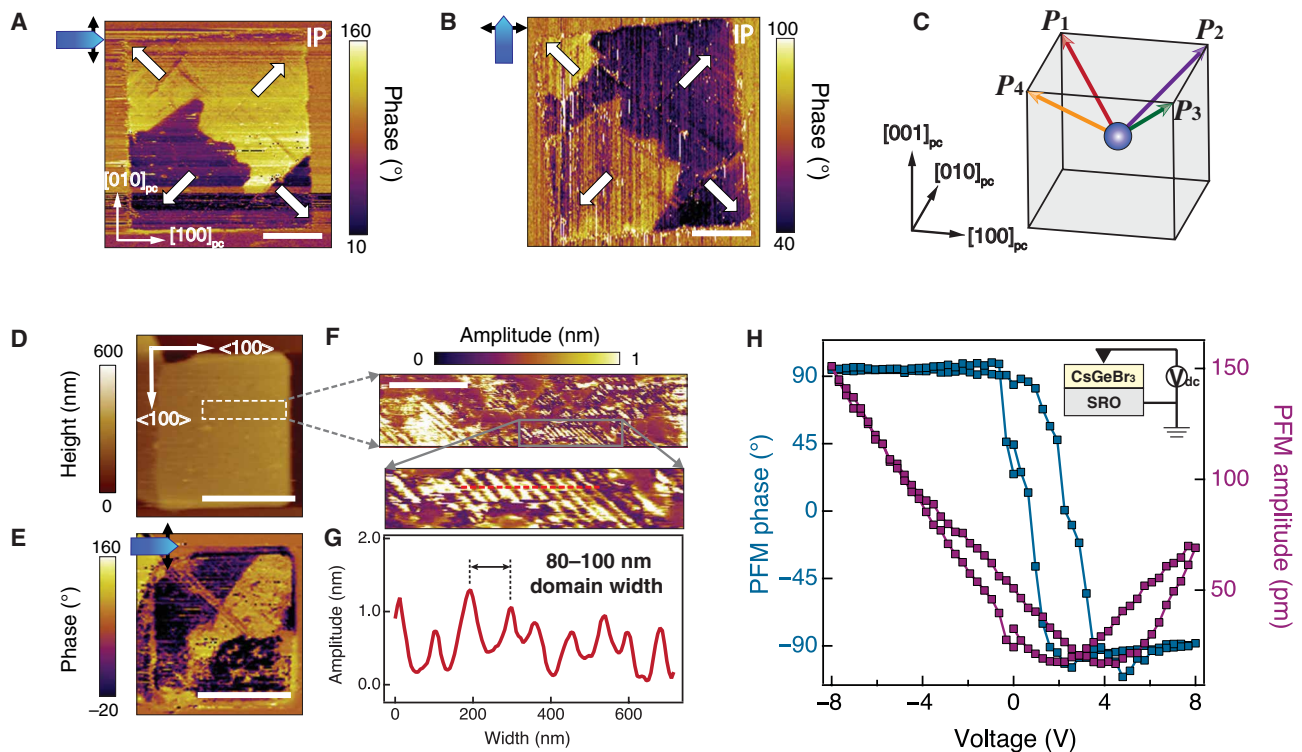


Fig. 3. Piezoelectric response and ferroelectric domain imaging via PFM. (A) In-plane (IP) PFM phase image of a CGB nanoplate. Scale bar, 5 μm . (B) In-plane PFM phase image of the same plate with sample rotation by 90° relative to (A). Scale bar, 5 μm . In both (A) and (B), the blue arrows refer to the cantilevers and the double-ended black arrows correspond to the in-plane polarization components that are detected, perpendicular to the cantilever axis. In-plane projections of the polarizations were shown by the white arrows. (C) Polarization vectors in the four domain variants were represented by P_1 , P_2 , P_3 , and P_4 along $[111]$, $[111]$, $[111]$, and $[111]$ pseudo-cubic (pc) directions, respectively. (D and E) AFM image (D) and in-plane PFM phase image (E) of another CGB nanoplate. Scale bars, 5 μm . (F) Zoomed-in in-plane PFM amplitude image of a region on the plate indicated in (D). Scale bar, 1 μm . The bottom shows a further zoomed-in image. (G) Corresponding line trace at red dashed line in (F). (H) Phase and amplitude switching spectroscopy loops for the CGB grown on SRO film, which formed a simple device structure (inset) with DC electric field applied.

to the variation of polarization directions in these small domains that would all contribute to the net direction of polarization in a larger microscopic domain, which is a quite common phenomenon in ferroelectric domain structures.

Along with the phase contrast imaging from PFM, local switching spectroscopy was performed to demonstrate the polarization switching behavior under the applied electric field. The piezoelectric behavior in the out-of-plane direction, manifested by the 180° phase hysteresis and the butterfly-shape amplitude loops (Fig. 3H), further supported the ferroelectricity in CGB. We performed this measurement for the CGB crystals (1 μm thick) grown on a conductive oxide perovskite film, i.e., SrRuO₃ (SRO) as a bottom electrode. As a consequence of inverse piezoelectric effect, the amplitude signal can represent the surface displacement of a local point area as a function of electric field applied to the scanning probe tip. The shift and asymmetry of the loop is due to the asymmetrical electrical contacts for top (Pt/Ir-coated Si) and bottom (SRO) electrodes.

Polarization-resolved SHG imaging

In addition to the scanning probe techniques, the polarization-resolved scanning SHG microscopic imaging, as a fast and noninvasive nonlinear optical method, offers an alternate way to investigate the correlations of structural symmetry, polarization, and domain configurations. Figure 4A depicts the experimental geometry, where the sample orientation can be aligned with the laboratory coordinate axes and the polarization of fundamental light can be well controlled.

The scanning microscopic imaging provides a spatial map of SHG intensity over the sample surface when illuminated with the fundamental beam (Materials and Methods). SHG is known as a domain symmetry-sensitive technique for probing polar material (33). While the existence of SHG signal demonstrated the inversion symmetry breaking and spontaneous polar state in the material shown in figs. S7 and S24, the dependence of SHG intensity on the fundamental light polarization can further reveal the local structural symmetry and the correlated spontaneous polarization variance of ferroelectric domains. Figure 4B shows a polar plot that describes the relationship between the SHG intensity $I_{2\omega}$ and the polarization angle φ for a single spot on a CGB nanoplate, which was obtained from a series of spectra under different φ values in a polarization sweep. It was identified that the SHG intensity varies with φ and reaches the highest and lowest with an interval of 90°. We further acquired the SHG intensity map by scanning over the entire nanoplate at several representative polarization angles, $\varphi = 45^\circ, 90^\circ, 135^\circ, 180^\circ$, as exhibited in Fig. 4 (C to F, respectively). It is thus possible to determine the direction vector of the ferroelectric polarization, \mathbf{P}_s , from the SHG intensity, on the basis of nonlinear optical tensor and conversion equations (fig. S25). However, it is not possible to distinguish between domains with antiparallel polarization, that is, to know the sign of \mathbf{P}_s . On the basis of the domain structure we obtained from the PFM phase-contrast imaging, we found that the divergent type of domain configuration on the nanoplate still fit for our SHG domain imaging results. It is worthwhile to mention that,

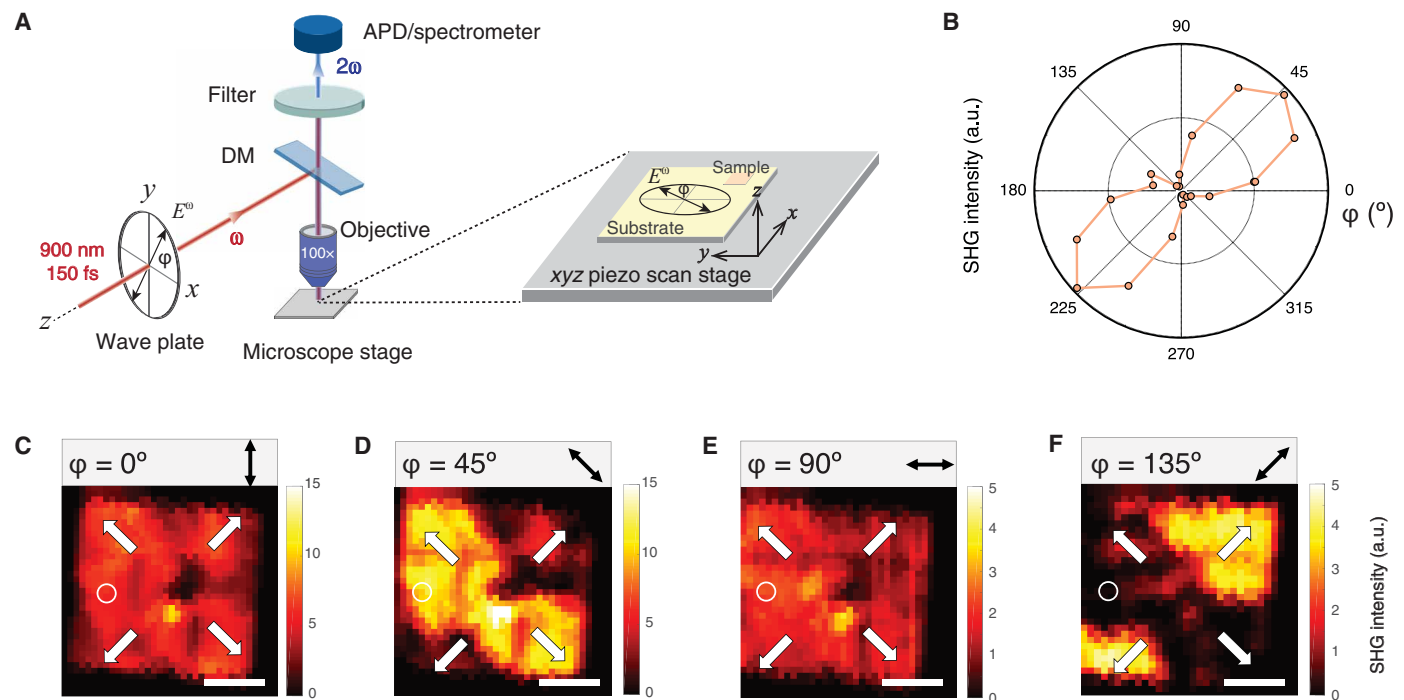


Fig. 4. Light polarization-resolved SHG measurement and spatial mapping. (A) Schematic representation of the experimental setup to illustrate the sample orientation with respect to the stage geometry and light propagation direction. The fundamental light pulses (900-nm wavelength) impinge on the sample CGB {001} surface at normal incidence, with a half-wave plate controlling their polarization. SHG light (450 nm) was detected in the reflection-mode scanning microscopy. The fundamental beam propagates along the z axis in laboratory coordinate system and polarizes along any direction in the x-y plane, where the polarization angle (φ) is defined by the azimuthal angle of incident electric field direction with respect to the x axis. DM, dichroic mirror. Filter: 580-nm short-wavelength pass filter. (B) Polar plots of SHG intensity versus polarization angle (φ) for a region depicted as the white circle on the plate mapped in (C) to (F). (C to F) Spatial mapping SHG intensity of the domain variants on the CGB nanoplate at different linear polarization states with φ and the double-ended black arrows indicated in each image. The white arrows indicate the possible configuration for the in-plane polarization orientations in the four domains. Scale bars, 5 μm .

for $\varphi = 45^\circ$ and $\varphi = 135^\circ$, the SHG intensity contrast (bright and dark regions) between domains switches, when the fundamental light polarization is orthogonal to each other (see analysis in the Supplementary Materials). This phenomenon also verifies that the in-plane component of spontaneous polarization is parallel to the surface diagonal direction of the nanoplate, which is 45° with respect to the nanoplate edge. Thus, for intermediate states $\varphi = 90^\circ$ and $\varphi = 180^\circ$, there is no observable contrast among the different domains as expected.

In summary, we have presented a comprehensive study on the emergence of ferroelectricity in a semiconducting all-inorganic halide perovskite CsGeX_3 , based on multilevel understanding and characterization from atomic to mesoscopic and macroscopic scales. The experimental findings in this work may inspire a series of important questions and directions for future exploration. For example, the mechanisms of ferroelectric domain formation could depend on the composition ($X = \text{Cl}, \text{Br}, \text{or I}$), crystal geometry, and sample thickness. Further investigations into the domain microstructures and atomic-scale polarization distributions would also be of great interest regarding this new ferroelectric halide system. Also, different excited-state carrier dynamics or structural phase transitions may occur in a ferroelectric semiconductor upon photoexcitation. The coupling between optical functionalities and ferroelectric responses might enable emerging physical phenomena and previously underexplored functionalities for material applications, such as light-controlled switches, ferroelectric photovoltaics, piezo-photonics, and other photoferroelectrics devices.

MATERIALS AND METHODS

Synthesis of nanostructures

The CGB perovskite nanowires and nanoplates were grown by a CVT method modified from the protocol for CsPbBr_3 synthesis that were previously developed (34–37) and were conducted in a tube furnace (Thermolyne 79300). An alumina boat loaded with mixed precursors of CsBr (99.999% trace metal basis, Sigma-Aldrich) and GeBr_2 (97%, Sigma-Aldrich) in a 1:1 molar ratio was put at the heating center of a 1-inch-diameter quartz tube. The substrates used for growth are either the freshly cleaved muscovite mica (Grade V2, Ted Pella Inc.) or Si wafer with amorphous silica on surface, which were placed at a specified position in the downstream region of the tube, which is 17 to 19 cm away from the tube center. A carrier gas of high-purity N_2 (99.999%) or Ar with a flowing rate of 200 sccm (standard cubic centimeters per minute) was used to purge the whole tube system to eliminate oxygen and moisture in the tube before materials growth. In the growth process, the center temperature was set to ramp from RT to 400°C with a heating rate of $50^\circ\text{C}/\text{min}$ and then was maintained at 400°C for 35 min to achieve the desirable nanoplate growth. The furnace was then shut down, and the whole growth system was naturally cooled down to RT. During the entire growth process, the gas flow rate was set and stabilized at 100 sccm. After the growth was completed, the samples should be taken out and stored in an Ar-filled glovebox, ready for the following characterizations. Both nanowires and nanoplates can form on mica and Si substrates. Longer nanowires tend to form on the hotter side (170° to 180°C) of the mica, while the majority of nanoplates can be found on the center region (140° to 160°C) of the mica. Nanowires and nanoplates grown on Si can be more easily transferred to other substrates (e.g., TEM grid) since most of them are

not horizontally distributed but vertically aligned or inclined to Si surface instead. Note that the growth of CsGeCl_3 and CsGeI_3 nanostructures should also be realized by replacing the Br precursors to Cl or I precursors. Same steps are followed, with slight modifications applied.

X-ray microdiffraction and diffraction

Synchrotron x-ray microdiffraction was performed at Beamline 12.3.2 of the Advanced Light Source, Lawrence Berkeley National Laboratory (LBNL). The CGB sample was loaded on a stage after sealing with Kapton tape to eliminate air exposure. The stage was rotated and maintained at 20° with respect to the horizontal direction. The detector (DECTRIS Pilatus 1M) was located at 40° with respect to the direct beam and around 151.014 mm from the sample. The detector geometry was calibrated using a finely ground Al_2O_3 reference sample. The measurement was performed in the monochromatic mode at 8 keV ($\lambda = 1.54982 \text{ \AA}$), with the x-ray microbeam directed to a designated area of about $200 \mu\text{m}^2$ for the measurement. As the size of x-ray microbeam is $1.5 \mu\text{m}$, the diffraction was taken by a raster scanning of the beam over the sample area with a step size around $0.5 \mu\text{m}$. The time for each measurement is around 20 min, with a data collection of around 100 frames that can be added together and generate the 2D diffraction images. The 2D diffraction images were processed using the x-ray microdiffraction analysis software to obtain the 1D XRD patterns by integration. The other XRD patterns were acquired from a Bruker AXS D8 advance diffractometer equipped with a lynxeye detector (Cu $K\alpha$ radiation, $\lambda = 1.54056 \text{ \AA}$).

SEM and TEM

SEM images were acquired using a JEOL JSM-6340F field-emission scanning electron microscope and a FEI Quanta 3D FEG/FIB SEM. For TEM, the CGB nanoplates and nanowires were transferred by lightly pressing a TEM grid on a substrate grown with dense materials. The TEM images and SAED patterns in Fig. 1 and EDS mappings in figs. S2 and S3 were acquired by FEI Titan microscope at the National Center for Electron Microscopy facility of the Molecular Foundry at LBNL. The electron microscope was operated at 300 kV for all measurements.

STEM and displacement vector mapping

STEM HAADF imaging was carried out on JEOL Grand ARM300CF equipped with a cold field-emission gun and double spherical aberration correctors with a spatial resolution of $\sim 0.7 \text{ \AA}$ operating at 300 keV in Irvine Materials Research Institute at the University of California, Irvine. STEM images were taken with the convergence angle of the incident electrons at 32 mrad and the collection angle at 90 to 165 mrad.

The high-resolution HAADF STEM imaging provides spatial resolution adequate to measure the atomic positions of the A and B site cations of CGB. The high-frequency noise was removed by applying an annular mask in frequency space, and then the initial peak positions were determined by identifying local maxima and refined by fitting Gaussian curves to obtain the atom center positions. Displacements were calculated as the difference between the center of each cation and the center of mass of its adjacent neighbors.

Cs and Ge atomic positions were measured by using 2D Gaussian fitting on their atomic columns to locate centers and record offsets. The polarization vectors on Ge are defined as the displacement of

Ge atom from the center of unit cell formed by the four Cs and four Br atoms. The polarization vectors on Cs are defined as the opposite displacement of Cs atom from the center of the unit cell formed by the four Ge and four Br atoms.

UV-vis and Raman spectroscopy

The absorption spectrum was obtained with a UV-vis spectrometer (UV-3101, Shimadzu). Raman spectroscopy was acquired from a Horiba Jobin-Yvon LabRAM confocal microscope with a 100× [0.60 numerical aperture (NA)] objective. A 633-nm laser (10 mW) was focused on the CGB nanoplate sample, and the Raman scattered photons were dispersed by 1800 g/cm grating and collected by the spectrometer, with data collection time of 100 s (exposure time of 10 s and accumulation number of 10). The analysis of Raman spectrum was performed in Igor Pro software with multipeak fitting function.

Nanowire device fabrication for electrical measurements

A shadow mask method and a DC/AC sputter system or a thermal evaporator were used to deposit metal contact as electrodes for the electrical measurements. Commercial TEM grid was used as a shadow mask (purchased from Ted Pella Inc., 150 mesh, model: 12563-CU) and was placed directly on top of substrates grown with CGB nanowires. The nanowires with TEM grid masks were subsequently sent into the chamber of a DC/AC sputter system (Edwards 306) for electrode deposition. Cr (which serves as an adhesion layer) and Cu film are deposited by bombarding the target material with high-energy ions from a plasma. The total thickness of the electrode is around 800 nm to 1 μm .

Thin-film device preparation

The CsGeI₃ thin films were prepared using thermal evaporations of two separate layers of CsI and GeI₂ sequentially on Pt-deposited SiO₂ substrate, followed by an annealing process to promote the formation of perovskite films (38). This film preparation method is not easily transferable to CGB so that we performed measurements on the CsGeI₃ films as the two share similar ferroelectric properties indicated by the structural origins and theoretical calculations. The Cu electrode pattern was deposited also by thermal evaporation with the TEM grid (from Ted Pella Inc., 400 mesh, model: 12575-CU) as the shadow mask.

Macroscopic *P-E* measurement

Ferroelectric measurements (*P-E* loop and PUND test) were taken using a Radiant Technologies Precision Multiferroic tester and performed using tungsten (W) probes to contact with the fabricated metallic electrodes. Hysteresis loops were taken at 10 to 20 kHz.

I-V characteristic measurement

The measurements were conducted on a single nanowire under vacuum in a probe station (Lakeshore, CPX-HF) located at the Molecular Foundry of LBNL. The light source used for illumination was a 300-W Xenon lamp (Asahi Spectra, MAX-303) equipped with a bandpass filter of 360 to 580 nm. The Agilent 4155C Semiconductor Parameter Analyzer was used for the electrical measurements.

PFM and local switching spectroscopy

PFM measurements were performed using a commercial scanning probe microscope (Asylum, MFP-3D). Dual-AC resonance tracking mode of PFM was conducted using a conductive Pt/Ir-coated

probe tip (NanoSensor, PPP-EFM) to image the domain structures and measure switching-spectroscopy piezoelectric hysteresis loops. The topographic AFM images can be obtained simultaneously from the contact mode of PFM scanning. For the vector PFM containing two in-plane PFM and one out-of-plane PFM imaging, we rotated the sample by 90° between the two in-plane PFM measurements. The local switching spectroscopy was performed using the same setup and probe tip on the CGB crystals grown on SRO film (conductive, as bottom electrode). A triangular voltage waveform (frequency of 0.025 Hz and bias of 8 V) was applied to collect both the amplitude and phase signals of modulated tip vibration as functions of the bias voltage. The driving amplitude of the tip is 1 V.

SHG measurement and microscopic polarimetry imaging

SHG measurements were performed in the Imaging Facilities of Molecular Foundry at LBNL. The light coming from a Coherent Chameleon Ultra II Ti:sapphire laser (700 to 1000 nm) with a pulse width of 150 fs and a repetition rate of 80 MHz was applied for the SHG spectroscopic and microscopic measurement. The incident light (frequency ω) was coupled into the microscope using a dichroic mirror (reflective for light of frequency ω and transparent for frequency 2ω), then was focused onto the sample with a 100× (0.95 NA) Nikon LU Plan Apo objective, and scanned across the sample for measuring SHG in a reflection geometry (Fig. 4A). The fundamental beam is exactly parallel to the optical axis of the microscope and incident on the sample at normal incidence. A short-pass filter (580 nm) was used inside the microscope to block the remaining fundamental beam (900 to 1000 nm) and separate out only the SHG photon (450 to 500 nm). The generated SHG signals were collected on an Andor Kymera spectrometer and an Andor iXon charge-coupled device or an Micro Photon Devices (MPD) avalanche photodiode (APD) detector for counting photons. The spectrometer can be used to confirm the detected photons at half of the wavelength of fundamental beam. The scanning SHG imaging was obtained through software-controlled moving of the MadCityLabs xyz-piezo stage where the sample was loaded. The scanned image has a diffraction-limited lateral resolution of the order of 300 to 500 nm for a fundamental wave in the near-infrared range.

The wavelength-dependent SHG spectra were acquired at three individual pumping wavelengths at 900, 950, and 1000 nm, respectively. All the other measurements were done with the fundamental wavelength tuned to 900 nm. We also acquired the power-dependent SHG spectra for verifying the SHG process by changing the input power of fundamental light to check whether the SHG intensity has a quadratic dependence on the power. The quadratic power dependence of the SHG intensity on the input power of incident light revealed that the signal detected by APD was only due to two-photon processes as expected. The temperature-dependent SHG measurement was performed on sample placed inside a sealed heating cell (homebuilt) at a low pressure (~1 torr, to prevent sample degradation).

In the SHG polarimetry measurement, all linear polarization states of input light are available by rotating a half-wave plate (HWP) in the laser beam path. Before the light passes through HWP, there is also a polarizer to enhance the degree of linear polarization. The HWP was mounted on a motorized rotation stage and controlled by the software, allowing for a continuous and precise rotation of incident polarization $E^0(\varphi)$ in the x - y plane of the laboratory coordinate system (x , y , z), where φ is the azimuthal angle of the fundamental light polarization. The HWP introduces a 180° difference between components

parallel to the fast axis of the wave plate and perpendicular to the fast axis. This allows arbitrarily rotating a linearly polarized state to any other linear state. For example, if the angle between the fast axis of the HWP and polarized light is θ , then the HWP will rotate the linear polarization state of the incoming light by 2θ . In our experiments, we acquired a sequence of SHG spectra from polarization sweep and scanning SHG intensity mappings at separate input polarizations.

Ab initio calculation details

Our density functional theory (DFT) calculations were performed with the Vienna Ab Initio Simulation Package (VASP) (39, 40) with projector-augmented waves and the Perdew-Burke-Ernzerhof (PBE) exchange-correlation functional (41, 42). We treated Cs (5s, 5p, 6s), Ge (3d, 4s, 4p), Cl (3s, 3p), Cl (4s, 4p), and I (5s, 5p) electrons as valence. We used a planewave energy cutoff of 800 eV and a Γ -centered k -point grid of $6 \times 6 \times 6$. Structural optimizations of the unit cell shape and size in addition to the internal coordinates were performed until the Hellman-Feynman forces were less than $0.01 \text{ eV } \text{\AA}^{-1}$, with the resulting structural details given in table S1. The spontaneous polarization was calculated using the Berry phase approach with interpolated structures between the cubic and polar rhombohedral structure used to obtain consistent branch cuts for the calculated polarizations (29, 30, 43).

Theory results for CsGeCl₃ and CsGeI₃

We also calculated the cubic and rhombohedral structures of CsGeCl₃ and CsGeI₃, and the resulting spontaneous polarization using both the Berry phase approach and estimates from the BECs. The results of the polarization calculations for the CsGeX₃ series are given in Table 1. From the Berry phase approach, we find very similar values of the spontaneous ferroelectric polarization across the series, with more significant contributions to the total value coming from electronic part for Cl, and decreasing down the periodic table. This is a result of the decreasing electronegativity difference as we move down the halide column, resulting in less tendency for electronic driven polarization. This is consistent with estimates of the ionic driven polarization obtained from the BECs—we find that the calculated polarization increases as we move down the halide column due to both the increased BEC and increased Ge off-centering going from Cl to Br to I.

SUPPLEMENTARY MATERIALS

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